

The Abdus Salam International Centre for Theoretical Physics



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Electron transport through nanostructures

Lecture 1

Quantum Dots: Coulomb blockade, tunneling, cotunneling

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Outline of the course:

• Quantum Dots

- Kondo effect in nano-devices
- From Fermi liquid to Luttinger liquid For reading:

Transport through QDs: W.G. van der Wiel et al, RMP 75 (2003) SET and Coulomb blockade: M.A.Kastner, RMP 64 (1992) Popular reading: Leo Kouwenhoven and Charles Marcus, Physics World 1998 See also in the web Lecture courses of Ya. Blanter, Y. Gefen, Yu. Galperin

* Some transparencies are courtesy of Yuval Gefen, Yaroslav Blanter and Yuri Galperin

Connection with other lectures:



Outline of this lecture

- What is Nano?
- Examples of QD:
- Vertical vs lateral QDs
- Diffusive vs ballistic QDs
- Metallic vs semiconductor QDs
- Open vs close QDs
- Coulomb blockade
- Sequential tunneling
- Elastic vs inelastic cotunneling
- "Universal" Hamiltonian



Modern electronic devices belong to mesoscopic scale

Nano means Big !?

Nanoscale objects do not fully belong to the microcosm

Many atoms, electrons, etc., are involved

Number of degrees of freedom is large



CMOS TECHNOLOGY



Intel's Norwood (Pentium 4 - 130 nm) processor

Intel's Prescott processor (released March 2004):

- 150 million transistors
- 90 nm design rules
- 3.4 GHz clock frequency

DRAM chips:

- 4 Gb chips demonstrated
- (~ 10⁹ transistors/cm²)

Two Dimensional Electron Gas (2DEG)





- Tune: gate potentials, temperature, field...
- Measure: I-V curves, conductance G...
- Aharonov-Bohm interferometry, dephasing, coherent state manipulation...

Quantum dots: from simple to complex





-----1µm













D.Goldhaber-Gordon et al (1998)

J.P.Kotthaus (1995)

A.Holleitner et al (2002)

L.W.Molenkamp et al (1995)

H.Jeong et al (2001)

C.Marcus et al (2003)





Self-assembled QD

B delta-doped



Self-assembled quantum dots are periodic arrays of "artificial atoms".

They are considered to be promising systems for heterostructure lasers.

Nanoelectromechanical shuttling: QD devices





J. Kotthaus et al, Nature Nanotechnology 2008

Cerocene

 $Ce(C_8H_8)_2$

Ytterbocene

Ce(COT)₂







COT = C8H8

 $Cp^* = C5Me5$, bipy = (NC5H4)2]

MolecularTransistor





H.Park et al, Nature 2000

Transition metals inside fullerens









Nanotube peapods: C₆₀ @ CNT





Realization of lateral QD in 2DEG





Characteristic parameters:

size: $100 \text{ A}^{\circ} \rightarrow 2 \mu m$

electrons: $0 \rightarrow$ hundreds

mobility

(of 2DEG in strong magnetic fields) original Integer Quantum Hall Effect current world record (Weizmann)

 $\sim (30-50) \cdot 10^3 \text{ cm}^2 / V \cdot \text{sec}$ $\sim 36 \cdot 10^6$

CONTROL:

- (mobility; disorder)
- Contact to leads



side gate

The quantum-dot structure studied at Delft and NTT in Japan is fabricated in the shape of a round pillar. The source and drain are doped semiconductor layers that conduct electricity, and are separated from the quantum dot by tunnel barriers 10 nm thick. When a negative voltage is applied to the metal side gate around the pillar, it reduces the diameter of the dot from about 500 nm to zero, causing electrons to leave the dot one at a time.

Vertical QDs

advantages: easy access to small # electrons, symmetric QDs

disadvantages: hard to control shape/size; dot-lead coupling



size: $30A^{\circ}$ and up $\lambda_{\rm F}$: a few A° **# electrons:** > many hundreds

originally: statistics of an ensemble today: can attach leads to a single QD little control: QD-lead coupling; size of QD special appeal: QDs with special properties: SC; magnetic...

NON INTERACTING ELECTRONS

diffusive vs. ballistic





diffusiveballistic $E_{th} = \hbar/(\text{diffusion time}) = \hbar/(L^2/D)$ $E_{th} = \hbar/(\text{time of flight}) = \hbar/(L/v_F)$



dirty ballistic

time of flight ≠ Thouless energy
(Altland , Gefen, Montambaux)



Open vs. Closed

 $\frac{\Gamma_c}{\hbar}$ = decay rate of a QD level into channel c

total level width =
$$\Gamma = \sum_{c} \Gamma_{c}$$

closed QD (charge on the dot is nearly quantized) $\Gamma < E_c$



Metallic quantum dots: many-electron system



Coulomb blockage



Al film Sn Sn Sn Sn Ov Al film

Ivar Giaever



To move an electron to a confined region one has to pay for its repulsion from existing electrons

1973

The principle of the Coulomb blockade



Why R matters? time delay $\delta t = eR/V$ duration $\tau \sim \hbar/eV$ $\delta t \gg \tau \rightarrow R \gg \hbar/e^2$

Energy stored is q²/2C





Because of environment capacitances it is difficult to observe CB in single junctions At |q| < e/2 the electron tunneling will increase the energy stored in the barrier - one has to pay for the tunneling by the bias voltage

Coulomb blockade



 $Q_0 = -(N + \frac{1}{2})e$

Q = -Ne

CHARGE

Q_o = - Ne



Single-electron transistor (SET)

Increasing gate voltage V_e

 $Q_0 = -(N + \frac{1}{2})e$



Coulomb staircase

Nonlinear transport: upon increasing V more charging states become available



LATERAL QDs : possible parameters

Temperature < 1 K (as low as 10-30 mK) elastic mean free path $\approx 1-150 \,\mu\text{m}$ $n_{c} \approx 10^{11} - 10^{12} \text{ cm}^{-2}$ $E_{\rm F} \approx 10 - 20 \, {\rm meV}$ $\lambda_{\rm F} \approx 50 \, \rm nm$ # electrons: 0 - hundreds single particle level spacing= $\Delta \sim (0.01 \text{ meV} \sim 0.1 \text{ K})$ Thouless energy = $E_{th} \sim (0.3 \text{ meV} \sim 3 \text{ K})$ charging energy = $E_c \sim (1 \text{ meV} \sim 10 \text{ K})$

THE "UNIVERSAL" HAMILTONIAN

$$H = H_{sp} + H_{int}$$
$$H_{int} = \frac{1}{2} \sum_{\alpha, \beta, \gamma, \delta} H_{\alpha\beta\gamma\delta} \widehat{\Psi}^{\dagger}_{\alpha\sigma_{1}} \widehat{\Psi}^{\dagger}_{\beta\sigma_{2}} \widehat{\Psi}_{\gamma\sigma_{2}} \widehat{\Psi}_{\delta\sigma_{1}}$$

$$H_{\alpha\beta\gamma\delta} = \int d\mathbf{r}_1 d\mathbf{r}_2 V(\mathbf{r}_1 - \mathbf{r}_2) \phi_\alpha(\mathbf{r}_1) \phi_\beta(\mathbf{r}_2) \phi^*_{\gamma}(\mathbf{r}_2) \phi^*_{\delta}(\mathbf{r}_1)$$

Note: only orbital indices (no spin-orbit)

$$H_{\text{int}} = H_{\text{int}}^{(0)} + H_{\text{int}}^{(1/g)}$$

$$1$$
universal non-universal, fluctuating

CHARGING HAMILTONIAN

$$H = H_{sp} + H_{int}$$

$$H_{int} = H_{int}^{(0)} + H_{int}^{(1/g)}$$

$$H_{int}^{(0)} \Rightarrow \hat{E}_{c} (\hat{n} - N_{0})^{2}$$

$$\rightarrow E_{c} (\sum \Psi_{\alpha}^{\dagger} \Psi_{\alpha}) \cdot (\sum \Psi_{\beta}^{\dagger} \Psi_{\beta}) - 2E_{c} N_{0} + E_{c} N_{0}^{2}$$

$$interaction \qquad \text{external gate V} \qquad \text{constant}$$

Metallic Quantum Dot: Universal Hamiltonian

Metallic grain or small island of electron gas

Quantum Dot

Electron-electron interactions in isolated metallic grains



Kurland, Aleiner, Altshuler (2000) Aleiner, Brouwer, Glazman (2002)

TRANSPORT THROUGH a QD: thermally activated conduction

 $H = H_{sp} + E_c (\hat{n} - N_0)^2 + H_{leads} + H_{tunneling}$ $H_{leads} = \sum \xi_k c_k^{\dagger} c_k \quad \text{for each lead}$



Tunneling in metals (No CB)



Tunneling and Coulomb blockade



Inelastic cotunneling



inelastic cotunneling

(excitations left behind)

state k on Left \rightarrow state k' on Right + Dot (n filled; m empty)

Elastic cotunneling



elastic cotunneling

(no excitations left behind)

Tunneling and co-tunneling (summary)





DISCRETE SPECTRUM QD: coherent vs. Incoherent transport

$$H = H_{L} + H_{R} + H_{dot} + H_{tun}$$

$$H_{dot} = \mathcal{E} \sum_{\sigma} n_{\sigma} + E_{c} n_{\uparrow} n_{\downarrow}$$

$$H_{tun} = t_{\alpha} c_{\alpha k \sigma}^{+} d_{\sigma} + h.c.$$
a single orbital level spin \uparrow or \downarrow

This is a story for next lecture!